- 1. (previously presented): Alkaline developable, photosensitive composition comprising
- (A) at least one alkaline soluble binder resin, prepolymer or monomer component;
- (B) at least one compound of formula I or II

 R_1 is C_4 - C_9 cycloalkanoyl, C_3 - C_{12} alkenoyl; C_1 - C_{20} alkanoyl which is unsubstituted or substituted by one or more halogen, CN or phenyl; or R_1 is benzoyl which is unsubstituted or substituted by one or more C_1 - C_6 alkyl, halogen, CN, OR_3 , SR_4 or NR_5R_6 ; or R_1 is C_2 - C_{12} alkoxycarbonyl or benzyloxycarbonyl; or phenoxycarbonyl which is unsubstituted or substituted by one or more C_1 - C_6 alkyl or halogen;

Ar₁ is C_6 - C_{20} aryl which is substituted 1 to 12 times by halogen, C_1 - C_{20} alkyl, benzyl, C_1 - C_{20} alkanoyl, or C_3 - C_8 cycloalkyl; or said C_6 - C_{20} aryl is substituted by phenyl or benzoyl each of which optionally is substituted by one or more OR_3 , SR_4 or NR_5R_6 ; or said C_6 - C_{20} aryl is substituted by C_2 - C_{12} alkoxycarbonyl optionally interrupted by one or more -O- and/or optionally substituted by one or more hydroxyl groups; or said C_6 - C_{20} aryl is substituted by phenoxycarbonyl, OR_3 , SR_4 , SOR_4 , SO_2R_4 or NR_5R_6 , wherein the substituents OR_3 , SR_4 or NR_5R_6 optionally form 5- or 6-membered rings via the radicals R_3 , R_4 , R_5 and/or R_6 with further substituents on the aryl ring of the C_6 - C_{20} aryl group or with one of the carbon atoms of the aryl ring of the C_6 - C_{20} aryl group; or, provided that R_1 is acetyl, Ar_1 is C_3 - C_9 heteroaryl, which is unsubstituted or substituted 1 to 7 times by halogen, C_1 - C_{20} alkyl, benzyl, C_1 - C_{20} alkanoyl, or C_3 - C_8 cycloalkyl; or said C_3 - C_9 heteroaryl is substituted by one or more OR_3 , SR_4 or NR_5R_6 ; or said C_3 - C_9 heteroaryl is substituted by C_2 - C_{12} alkoxycarbonyl optionally interrupted by one

or more -O- and/or optionally substituted by one or more hydroxyl groups; or said C₃-C₉ heteroaryl is

x is 2 or 3:

substituted by phenoxycarbonyl, OR₃, SR₄, SOR₄, SO₂R₄ or NR₅R₆;

 C_{12} alkyl, C_3 - C_8 cycloalkyl, benzyl; phenyl which is unsubstituted or substituted by one or more OR_3 , SR_4 or NR_5R_6 ; benzoyl which is unsubstituted or substituted by one or more OR_3 , SR_4 or NR_5R_6 ; C_1 - C_{12} alkoxycarbonyl optionally interrupted by one or more -O- and/or optionally substituted by one or more OH, phenoxycarbonyl, OR_3 , SR_4 , SOR_4 , SO_2R_4 or NR_5R_6 ;

or
$$M_1$$
, when x is 3, is or M_4 or M_4 , each of which optionally is

substituted 1 to 12 times by halogen, C_1 - C_{12} alkyl, C_3 - C_8 cycloalkyl; phenyl which is unsubstituted or substituted by one or more OR_3 , SR_4 or NR_5R_6 ; benzyl, benzoyl, C_1 - C_{12} alkanoyl; C_2 - C_{12} alkoxycarbonyl optionally interrupted by one or more -O- and/or optionally substituted by one or more hydroxyl groups, phenoxycarbonyl, OR_3 , SR_4 , SOR_4 , SO_2R_4 or NR_5R_6 ;

 M_2 is a direct bond, -O-, -S-, -SS-, -NR₃-, -(CO)-, C₁-C₁₂alkylene, cyclohexylene, phenylene, naphthylene, -(CO)O-(C₂-C₁₂alkylene)-O(CO)-, -(CO)O-(CH₂CH₂O)_n-(CO)- or -(CO)-(C₂-C₁₂-alkylene)-(CO)-; or M_2 is C₄-C₁₂alkylene or C₄-C₁₂alkylenedioxy-, each of which is optionally interrupted by 1 to 5 -O-, -S- and/or -NR₃-;

 M_3 is a direct bond, -CH₂-, -O-, -S-, -SS-, -NR₃- or -(CO)-;

$$M_4$$
 is N , N or N

 R_3 is hydrogen or C_1 - C_{20} alkyl; or R_3 is C_2 - C_{12} alkyl which is substituted by -OH, -SH, -CN, C_3 - C_6 alkenoxy, -OCH₂CH₂CN, -OCH₂CH₂(CO)O(C_1 - C_4 alkyl), -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl, - (CO)OH, -(CO)O(C_1 - C_4 alkyl), -N(C_1 - C_4 alkyl)₂, or morpholinyl; or R_3 is C_2 - C_1 2alkyl which is interrupted by one or more -O-; or R_3 is -(CH₂CH₂O)_{n+1}H, -(CH₂CH₂O)_n(CO)- C_1 - C_8 alkyl, C_1 - C_8 alkanoyl, C_3 - C_1 2alkenyl, C_3 - C_6 alkenoyl, C_3 - C_8 cycloalkyl; or R_3 is benzoyl which is unsubstituted or substituted by one or more C_1 - C_6 alkyl, halogen, -OH or C_1 - C_4 alkoxy; or R_3 is phenyl or naphthyl each of which is unsubstituted or substituted by halogen, -OH, C_1 - C_1 2alkyl, C_1 - C_1 2alkoxy, phenyl- C_1 - C_3 -alkoxy, phenoxy, C_1 - C_1 2alkylsulfanyl, phenylsulfanyl, -N(C_1 - C_1 2alkyl)₂, diphenylamino or -(CO) R_7 ; or R_3 is phenyl- C_1 - C_3 alkyl, or Si(C_1 - C_6 alkyl)_r(phenyl)_{3-r};

r is 0, 1, 2 or 3;

n is 1 to 20:

 R_4 is hydrogen, C_1 - C_{20} alkyl, C_3 - C_{12} alkenyl, C_3 - C_8 cycloalkyl, phenyl- C_1 - C_3 alkyl; C_2 - C_8 alkyl which is substituted by -OH, -SH, -CN, C_3 - C_8 alkenoxy, -OCH $_2$ CH $_2$ CN, -OCH $_2$ CH $_2$ (CO)O(C_1 - C_4 alkyl), -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl, -(CO)OH or -(CO)O(C_1 - C_4 alkyl); or R_4 is C_2 - C_{12} alkyl which is interrupted by one or more -O- or -S-; or R_4 is -(CH $_2$ CH $_2$ O) $_{n+1}$ H, -(CH $_2$ CH $_2$ O) $_n$ (CO)- C_1 - C_8 alkyl, C_2 - C_8 alkanoyl, C_3 - C_{12} alkenyl, C_3 - C_6 alkenoyl; or R_4 is phenyl or naphthyl each of which is unsubstituted or substituted by halogen, C_1 - C_{12} alkyl, C_1 - C_{12} alkoxy or -(CO) R_7 ;

 R_5 and R_6 independently of each other are hydrogen, C_1 - C_{20} alkyl, C_2 - C_4 hydroxyalkyl, C_3 - C_5 alkenyl, C_3 - C_8 cycloalkyl, phenyl- C_1 - C_3 alkyl, C_1 - C_4 alkanoyl, C_3 - C_{12} alkenoyl, benzoyl; or are phenyl or naphthyl each of which is unsubstituted or substituted by C_1 - C_{12} alkyl or C_1 - C_{12} alkoxy; or R_5 and R_6 together are C_2 - C_6 alkylene optionally interrupted by -O- or -NR $_3$ - and/or optionally substituted by hydroxyl, C_1 - C_4 alkoxy, C_2 - C_4 alkanoyloxy or benzoyloxy;

 R_7 is hydrogen, C_1 - C_{20} alkyl; or is C_2 - C_8 alkyl which is substituted by halogen, phenyl, -OH, -SH, -CN, C_3 - C_6 alkenoxy, -OCH $_2$ CH $_2$ CN, -OCH $_2$ CH $_2$ (CO)O(C_1 - C_4 alkyl), -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl, -(CO)OH or -(CO)O(C_1 - C_4 alkyl); or R_7 is C_2 - C_{12} alkyl which is interrupted by one or more -O-; or R_7 is -(CH $_2$ CH $_2$ O) $_{n+1}$ H, -(CH $_2$ CH $_2$ O) $_n$ (CO)- C_1 - C_8 alkyl, C_3 - C_{12} alkenyl, C_3 - C_8 cycloalkyl; phenyl optionally substituted by one or more halogen, -OH, C_1 - C_{12} alkyl, C_1 - C_{12} alkoxy, phenoxy, C_1 - C_{12} alkylsulfanyl, phenylsulfanyl, -N(C_1 - C_{12} alkyl) $_2$, or diphenylamino; and

(C) a photopolymerizable compound.

- 2. **(original):** Photosensitive composition according to claim 1, wherein compound (A) is an oligomeric or polymeric compound.
- 3. **(original):** Photosensitive composition according to claim 2, wherein the photopolymerizable compound (C) is a liquid.
- 4. (previously presented): Photosensitive composition according to claim 1, wherein component (B) is a compound of formula I or II, wherein
- R_1 is C_2 - C_6 alkanoyl or C_2 - C_5 alkoxycarbonyl; or R_1 is benzoyl which is unsubstituted or substituted by one or more C_1 - C_6 alkyl or halogen;
- Ar₁ is phenyl or naphthyl,

each of these radicals is unsubstituted or substituted 1 to 5 times by halogen, C_1 - C_2 0alkyl, benzyl or C_1 - C_2 0alkanoyl; or said phenyl or naphthyl is substituted by phenyl or benzoyl, each of which optionally is substituted by one or more OR_3 , SR_4 or NR_5R_6 ; or said phenyl or naphthyl is substituted by C_2 - C_{12} alkoxycarbonyl optionally interrupted by one or more -O- and/or optionally substituted by one or more OR_3 , SR_4 or SR_6 0, wherein the substituents OR_3 1, SR_4 2 or SR_6 2 optionally form 5- or 6-membered rings SR_6 3 the radicals SR_6 4, SR_6 5 and/or SR_6 6 with further substituents on the phenyl or naphthyl ring or with one of the carbon atoms of the phenyl or naphthyl ring;

or Ar_1 is furyl, pyrrolyl, thienyl, benzofuranyl, indolyl, benzothiophenyl or pyrridyl, provided that R_1 is acetyl; wherein each of these radicals is unsubstituted or substituted 1 to 4 times by halogen, C_1 - C_{20} alkyl, benzyl, C_3 - C_8 cycloalkyl, phenyl, C_1 - C_{20} alkanoyl, benzoyl, C_2 - C_{12} alkoxycarbonyl, phenoxycarbonyl, OR_3 , SR_4 , SOR_4 , SO_2R_4 or NR_5R_6 ;

x is 2;

$$M_1$$
 is a group M_2 , M_3 or M_3

 C_{12} alkyl, benzyl, OR_3 , SR_4 or NR_5R_6 ; or by phenyl which is unsubstituted or substituted by one or more OR_3 , SR_4 or NR_5R_6 ; or by benzoyl which is unsubstituted or substituted by one or more OR_3 , SR_4 or

NR₅R₆; or by C₁-C₁₂alkanoyl; or by C₂-C₁₂alkoxycarbonyl optionally interrupted by one or more -O-and/or optionally substituted by one or more hydroxyl groups;

 M_2 is a direct bond, -O-, -S-, -SS-, -NR₃-, -(CO)-, C₁-C₁₂alkylene, phenylene, -(CO)O-(C₂-C₁₂alkylene)-O(CO)-, -(CO)O-(CH₂CH₂O)_n-(CO)- or -(CO)-(C₂-C₁₂-alkylene)-(CO)-; or M_2 is C₄-C₁₂alkylene or C₄-C₁₂alkylenedioxy-, each of which is optionally interrupted by 1 to 5 -O-, -S- and/or -NR₃-;

 M_3 is a direct bond, -CH₂-, -O-, -S-, -NR₃- or -(CO)-;

 R_3 is hydrogen or C_1 - C_{20} alkyl; or R_3 is C_2 - C_{12} alkyl which is substituted by -OH, -SH, -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl, -(CO)O(C_1 - C_4 alkyl), -N(C_1 - C_4 alkyl)₂, -N(C_1 - C_4 alkyl)₂, -N(C_1 - C_4 - C_4 - C_1 - C_4 -

n is 1 to 20;

R₄ is hydrogen, C_1 - C_{20} alkyl, C_3 - C_{12} alkenyl, phenyl- C_1 - C_3 alkyl; C_2 - C_8 alkyl which is substituted by -OH, -SH, -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl or -(CO)O(C_1 - C_4 alkyl); or R₄ is C_2 - C_{12} alkyl which is interrupted by one or more -O- or -S-; or R₄ is -(CH₂CH₂O)_{n+1}H, -(CH₂CH₂O)_n(CO)- C_1 - C_8 alkyl, C_2 - C_8 alkanoyl, C_3 - C_{12} alkenyl, C_3 - C_6 alkenoyl; or R₄ is phenyl or naphthyl each of which is unsubstituted or substituted by halogen, C_1 - C_{12} alkyl, C_1 - C_{12} alkoxy or -(CO)R₇;

 R_5 and R_6 independently of each other are hydrogen, C_1 - C_{20} alkyl, C_2 - C_4 hydroxyalkyl, C_2 - C_{10} alkoxyalkyl, phenyl- C_1 - C_3 alkyl, C_1 - C_4 alkanoyl, C_3 - C_{12} alkenoyl, benzoyl; or are phenyl or naphthyl each of which is unsubstituted or substituted by C_1 - C_{12} alkyl or C_1 - C_{12} alkoxy; or R_5 and R_6 together are C_2 - C_6 alkylene optionally interrupted by -O- or -NR₃- and/or optionally substituted by hydroxyl, C_1 - C_4 alkoxy, C_2 - C_4 alkanoyloxy or benzoyloxy; and

 R_7 is hydrogen, C_1 - C_{20} alkyl; or is C_2 - C_8 alkyl which is substituted by halogen, phenyl, -OH, -SH, C_3 - C_6 alkenoxy, -O(CO)- C_1 - C_4 alkyl, -O(CO)-phenyl or -(CO)O(C_1 - C_4 alkyl); or R_7 is C_2 - C_{12} alkyl which is interrupted by one or more -O-; or R_7 is -(CH $_2$ CH $_2$ O) $_{n+1}$ H, -(CH $_2$ CH $_2$ O) $_n$ (CO)- C_1 - C_8 alkyl or C_3 - C_{12} alkenyl; or is phenyl optionally substituted by one or more halogen, C_1 - C_{12} alkyl, C_1 - C_{12} alkoxy, phenoxy, C_1 - C_{12} alkylsulfanyl, phenylsulfanyl, -N(C_1 - C_{12} alkyl) $_2$, or diphenylamino.

5. (previously presented): Photosensitive composition according to claim 1, wherein component (B) is a compound of formula I or II, wherein

 R_1 is C_2 - C_4 alkanoyl;

 Ar_1 is phenyl or naphthyl, each of which is unsubstituted or substituted by halogen, C_1 - C_8 alkyl, NR_5R_6 or OR_3 , wherein the substituents OR_3 , optionally form 5- or 6-membered rings *via* the radicals R_3 with further substituents on the phenyl or naphthyl ring; or Ar_1 is 2-furyl, 2-pyrrolyl, 2-thienyl, 3-indolyl, provided that R_1 is acetyl;

 \mathbf{M}_1 is

x is 2;

 R_3 is C_1 - C_{20} alkyl; or R_3 is C_2 - C_{12} alkyl which is substituted by OH, -O(CO)- C_1 - C_4 alkyl, -N(C_1 - C_4 alkyl)₂, -N(CH₂CH₂OH)₂, -N[CH₂CH₂O-(CO)- C_1 - C_4 alkyl or morpholinyl; or R_3 is C_2 - C_{12} alkyl which is interrupted by one or more -O-; or R_3 is -(CH₂CH₂O)_{n+1}H or -(CH₂CH₂O)_n(CO)- C_1 - C_4 alkyl;

n is 1 to 3; and

R₅ and R₆ are C₁-C₄alkyl.

6.(original): Photosensitive composition according to claim 1, wherein the oligomer or polymer (A) is a binder polymer.

- 7. (original): Photosensitive composition according to claim 6, wherein the binder polymer is a copolymer of (meth)acrylate and (meth)acrylic acid, or a resin obtained by the reaction of a saturated or unsaturated polybasic acid anhydride with a product of the reaction of an epoxy compound and an unsaturated monocarboxylic acid, or is an addition product formed between a carboxyl group-containing resin and an unsaturated compound having an α,β -unsaturated double bond and an epoxy group.
- 8. (original): Photosensitive composition according to claim 1, which additionally to the components (A), (B) and (C) comprises at least one photosensitizer compound (D).
- 9. (previously presented): Photosensitive composition according to claim 8, comprising 100 parts by weight of component (A), 0.015 to 120 parts by weight of component (B), 5 to 500 parts by weight of component (C) and 0.015 to 120 parts by weight of component (D).

- 10.(original): Photosensitive composition according to claim 1, comprising further additives (E), which are selected from the group consisting of epoxy compounds, thermal polymerization inhibitors, inorganic fillers, colourants, epoxy curing agents, amines, chain transfer agents, thermal radical initiators, photoreducable dyes, optical brighteners, thickeners, antifoaming agents and leveling agents, in particular inorganic fillers.
- 11. (original): Photosensitive composition according to claim 1, additionally comprising an epoxy compound which contains at least two epoxy groups in the molecule.
- 12. (original): Solder resist comprising a composition according to claim 1.
- 13. (original): Color filter resist comprising a composition according to claim 1.
- 14. **(orignal):** Process for the photopolymerization of compounds containing ethylenically unsaturated double bonds, which comprises irradiating a composition according to claim 1 with electromagnetic radiation in the range from 150 to 600 nm.
- 15. (original): Coated substrate which is coated on at least one surface with a composition according to claim 1.
- 16. **(original):** Process for the production of relief images, wherein a coated substrate according to claim 15 is subjected to imagewise exposure with electromagnetic radiation in the range from 150 to 600 nm, and then the unexposed portions are removed with a solvent.
- 17. **(original):** A color filter prepared by providing red, green and blue (RGB) color elements and, optionally a black matrix, all comprising a photosensitive composition according to claim 1 and a pigment on a transparent substrate and providing a transparent electrode either on the surface of the substrate or on the surface of the color filter layer.

- 18. (original): Process for forming images, wherein
- (1) the components of a composition according to claim 1 are mixed,
- (2) the resulting composition is applied to the substrate,
- (3) the solvent, if present, is evaporated, at elevated temperature,
- (4) the coated substrate is patternwise exposed to irradiation,
- (5) the irradiated sample is developed with aqueous alkaline solution, thereby removing the uncured areas and
- (6) the sample is thermally cured.